ELECTRON DIFFRACTION STUDY OF THE MOLECULAR STRUCTURE OF TRIFLUOROMETHYL HYPOFLUORITE*

F. P. DIODATI^{**} AND L. S. BARTELL^{***}

Department of Chemistry, The University of Michigan, Ann Arbor, Mich. 48104 (U.S.A.) (Received August 11th, 1970)

ABSTRACT

The following structural parameters and estimated standard deviations were found for trifluoromethyl hypofluorite: $r_g(C-F) = 1.319 \pm 0.003$ Å, $r_g(C-O) = 1.395 \pm 0.006$ Å, $r_g(O-F) = 1.421 \pm 0.006$ Å, $\sphericalangle(F-C-F) = 109.4 \pm 1^\circ$. $\measuredangle(C-O-F) = 104.8 \pm 0.6^\circ$, assuming a C_{3v} symmetry for the CF₃ group, and a staggered conformation. Diffracted intensities indicate a bending of $4.1 \pm 0.8^\circ$ of the C-O bond from the three-fold axis of the trifluoromethyl group and a torsional oscillation about the C-O bond corresponding to a potential barrier of 2.5 ± 0.5 kcal/mole.

INTRODUCTION

The unusual chemical and physical properties of highly fluorinated substances make them interesting subjects for investigation. As part of a continuing program of research on such compounds we report here an analysis of the structure of CF₃OF. Infrared studies have been published^{1,2}, but detailed structure parameters have not been determined previously.

^{*} Based on a dissertation by F. P. Diodati in partial fulfillment of requirements for the degree of Doctor en Física, Universidad de La Plata, 1970. For a tabulation of experimental intensity data for CF_3OF , order document No. 01144 from ASIS National Auxiliary Publications Service, c/o CCM Information Sciences, Inc., 22 West 34th Street, New York, N.Y. 10001, remitting \$1.00 for microfiche or \$3.00 for photocopies.

^{**} From Departamento de Física, Facultad de Ingeniería, Universidad de Buenos Aires, now at Michigan with a fellowship from Consejo Nacional de Investigaciones Científicas y Técnicas, República Argentina.

^{***} Author to whom correspondence concerning reprints should be addressed.

EXPERIMENTAL SECTION

A sample of CF_3OF was purchased from Penninsular Chemical Research, Inc. Impurities detected by chromatography and infrared analysis were removed according to procedures described in the literature¹. A purification by low temperature filtration and successive distillations was performed until the infrared spectrum revealed no contaminants.

Electron diffraction patterns were taken with a unit described previously³. Patterns were recorded on Electron Image Plates at camera distances of 21-, 11-, and 7-cm using an r^3 sector. The relation between exposure and absorbancy was assumed to be

 $A = A_0(1 - e^{-2cE})$

according to which, with the additional criterion that $E \approx A$ for weak exposure, it is possible to relate the calibration constants with the absorbancy at saturation of the emulsion. Carbon tetrachloride patterns, heavily exposed, yielded a value of 5.55 ± 0.05 for A_0 .

ANALYSIS OF DATA

Following the usual procedure at the University of Michigan⁴, averaged experimental leveled intensities corresponding to the three camera ranges were calculated from the microphotometer readings of nine patterns. A range of 4.4 < s < 51.2 was covered.

After finding the proper graphical backgrounds for the three leveled intensities using the usual criteria, a blended intensity curve including all the experimental data was constructed. The final least-squares refinements were performed on this curve, adopting a value of $a = 2 \text{ Å}^{-1}$ for the asymmetry parameter for all bonded and nonbonded distances. A preliminary theoretical model available from a previous study of three patterns taken with a different unit* proved helpful in the analysis.

An optimum weight matrix was not used, but instead, a diagonal weight matrix was adopted with elements proportional to s^2 except for the beginning and final few points which were weighted more lightly.

As previously reported³, the effect of correlation between the experimental measurements was considered in the final standard deviations assigned.

A radial distribution function was calculated with the usual corrections⁵⁻⁸. In the Degard damping factor a value of 0.0015 for b was used. The elastic and inelastic atomic form factors were from refs. 9 and 10, respectively.

^{*} At Department of Physics, Faculty of Engineering, University of Buenos Aires.

STRUCTURE OF TRIFLUOROMETHYL HYPOFLUORITE

During the process of the analysis it was necessary to impose some symmetry constraints, including for example, the assignment of C_{3v} to the trifluoromethyl group and C_s for the entire molecule. It was not feasible to derive more than one independent amplitude of vibration from each composite peak in the radial distribution curve.

A significantly improved fit resulted if the C-O bond was allowed to move away from the three-fold axis of CF₃, toward the CF₃ fluorine in the C_s mirror plane, as is shown in Fig. 1. A further improvement was obtained if the OF group was assumed to be undergoing restricted rotation relative to the CF₃ group. The torsional potential function¹¹ giving the optimum fit possessed minima at staggered conformations and a barrier of 2.5 ± 0.5 kcal/mole.



Fig. 1. Structural model for CF₃OF.



Fig. 2. Experimental radial distribution function for CF₃OF; $\Delta f(r) = f(r)_{exp} - f(r)_{calc}$.

RESULTS

The difficulties imposed by the poor resolution of the internuclear distances, as illustrated in Fig. 2, are worth noting. From four peaks must be determined six geometric parameters (or seven, including the mean torsional twist angle). From this unpromising starting point it proved to be possible to extract a unique structure, with errors only several-fold larger than normal, by virtue of the restrictions imposed by geometric consistency. As a check, the structure refinements were made from a variety of different initial structures.

Table 1 gives the results of the analysis. Indices of resolution are lower than usual, probably due to the method of developing the plates. Table 2 lists the values of the correlation coefficients between the independent structure parameters. Fig. 3 shows the experimental and theoretical reduced intensity functions, sM(s), and the difference between them.

TABLE 1

STRUCTURAL PARAMETERS AND ESTIMATED STANDARD ERRORS FOR CF_3OF

	$r_{g}(A)$		lg(Å)	Angles (degrees)		
C-F	1.319±0.003	C-F, C-O; O-F	0.046±0.005	$\alpha = 109.4 \pm 1.0$		
C0	1.395±0.006	$F_1 \cdots F_2, F \cdots O; C \cdots F$	$5 0.061 \pm 0.006$	$\beta = 4.1 \pm 0.8$		
O-F	1.421 ± 0.006	$F_2 \cdots F_4$	0.061 ± 0.009	$\gamma = 104.8 \pm 0.6$		
$\mathbf{C} \cdots \mathbf{F_4}$	2.230 ± 0.009	$F_1 \cdots F_4$	0.061 ± 0.009			
$O \cdots F_1$	2.160 ± 0.015					
$\mathbf{O} \cdots \mathbf{F}_{\mathbf{z}}$	2.244 ± 0.007	Indices of resolution 21-cm	n data = 0.82			
$F_1 \cdots F_2$	2.153 ± 0.008	11-cm data = 0.85				
$F_2 \cdots F_4$	2.608 ± 0.010	7-cn	n data $= 0.75$			
$F_1 \cdots F_4$	3.383±0.010					

TABLE 2

diagonal elements of zeroth order error matrix^a and matrix of correlation coefficients^b for CF_3OF

	<i>r</i> _{c-0}	r _{C-F}	r _{o-F}	β	δ	γ	l _{C-F}	$l_{F_1-F_2}$	R
$\sigma_{(\theta_i)}^{a,b}$	3.15	0.82	2.87	395.70	260.00	323.80	1.06	1.55	4.82
$r_{\rm C-0}$	1.00	-0.66	-0.72	000.24	-000.12	-000.29	-0.34	-0.52	-0.15
r _{C-F}		1.00	0.60	-000.21	-000.24	-000.24	0.34	0.14	0.13
70-F			1.00	-000.31	-000.11	000.04	-0.02	0.36	0.23
β				1.00	-000.72	-000.17	-0.01	-0.25	-0.09
δ					1.00	-000.53	-0.07	0.57	0.06
γ						1.00	0.10	0.34	-0.04
l _{C-F}							1.00	0.27	0.42
$l_{F_1-F_2}$								1.00	0.41
R									1.00

^a Corresponds to M_x° of L. S. BARTELL, Acta Cryst., 25 (1969) S76. Values are $\times 10^3$ based on 150 points interpolated from 336 data points. Units for distances and amplitudes are in Å, for angles, in degrees.

^b Correspond to the ρ_{lj} of ref. 18. Correlations for $l_{F_2-F_4}$ and $l_{F_1-F_2}$ have not been listed because they are significantly smaller.



Fig. 3. Experimental and calculated reduced molecular intensity functions for CF₃OF; $\Delta[sM(s)] = sM(s)_{exp} - sM(s)_{calc}$.

DISCUSSION

Comparisons between the structure parameters of CF₃OF and those of selected molecules are instructive. For example, the C-F bonds do not differ significantly in length from those in CF₄ (1.323±0.005 Å), but are shorter than those in CF₃ groups attached to less electronegative atoms, cf. CF₃Cl (1.328±0.002 Å)¹²⁻¹⁴ and CF₃CH₃ (1.335±0.005 Å). Similarly, the C-O bond length is 0.033 Å shorter than that in methanol (1.428±0.003 Å)¹⁵. The C-O bond tilts away from the CF₃ axis by about the same amount as reported for methanol (refs. 16-18).

The above trends are qualitatively in accord with the double-bond-no-bond resonance theory¹⁹, and with Gillespie's valence shell electron pair theory²⁰. To complete the comparison between experiment and simple models on a basis more amenable to numerical analysis, extended Hückel molecular orbital calculations²¹ were performed on CF₃OF and CH₃OH. Orbital exponents were taken from Clementi and Raimondi²² together with the valence orbital ionization potentials (voip's) of Basch et al.²³. Using zero charge voip's and identical C–O bc nd lengths as input parameters for CF₃OF and CH₃OH, we obtained a 10 % greater C–O overlap population for CF₃OF than for CH₃OH, consistent with the shorter bond

in the former molecule. Adopting ligand charges for the volte's of CF_3OF to yield an MO gross population of 2.6 valence electrons on the carbon, and placing the C-O bond on the CF_3 axis, we computed that the staggered conformation was 1.7 kcal/ mole more stable than the eclipsed form, in fair agreement with the present experiment.

ACKNOWLEDGEMENTS

We are indebted to Professor E. E. Galloni for the assistance in all the work done at the University of Buenos Aires, to Dr. P. J. Aymonino for supplying the sample for experiments in Buenos Aires, to all the members of the Laboratory of Electron Diffraction at the University of Michigan for the valuable collaboration during the execution of this research, and to Dr. Hans B. Bürgi for his very opportune suggestions and helpful discussions. We are pleased to acknowledge a generous allowance of computing time from the Michigan Computing Center.

REFERENCES

- 1 P. J. AYMONINO, J. Inorg. Nucl. Chem., 27 (1965) 2675.
- 2 P. M. WILT AND E. A. JONES, J. Inorg. Nucl. Chem., 29 (1967) 2108.
- 3 L. S. BARTELL, in A. WEISSBERGER AND B. W. ROSSITER (Editors), *Physical Methods in Chemistry*, 4th Ed., Interscience, New York, in press.
- 4 L. S. BARTELL, D. A. KOHL, B. L. CARROLL AND R. M. GAVIN, JR., J. Chem. Phys., 42 (1965) 3079; R. A. BONHAM AND L. S. BARTELL, J. Chem. Phys., 31 (1959) 702.
- 5 L. S. BARTELL, L. O. BROCKWAY AND R. H. SCHWENDEMAN, J. Chem. Phys., 23 (1955) 1854.
- 6 R. A. BONHAM AND T. UKAJI, J. Chem. Phys., 36 (1962) 72.
- 7 L. S. BARTELL AND L. O. BROCKWAY, J. Chem. Phys., 32 (1960) 512.
- 8 K. KUCHITSU AND L. S. BARTELL, J. Chem. Phys., 35 (1961) 1945.
- 9 H. L. COX, JR. AND R. A. BONHAM, J. Chem. Phys., 47 (1967) 2599.
- 10 C. TAVARD, D. NICOLAS AND M. ROUAULT, J. Chim. Phys., 64 (1967) 540.
- 11 R. A. BONHAM AND L. S. BARTELL, J. Am. Chem. Soc., 81 (1959) 3491.
- 12 C. G. THORNTON, University Microfilm, Ann Arbor, Michigan, Publication No. 7746.
- 13 L. S. BARTELL AND L. O. BROCKWAY, J. Chem. Phys., 23 (1955) 1860.
- 14 W. F. EDGELL, G. B. MILLER AND J. W. AMY, J. Am. Chem. Soc., 79 (1957) 2391.
- 15 K. KIMURA AND M. KUBO, J. Chem. Phys., 30 (1959) 151.
- 16 E. V. IVASH AND D. M. DENNISON, J. Chem. Phys., 21 (1953) 1804.
- 17 P. VENKATESWARLU AND W. GORDY, J. Chem. Phys., 23 (1955) 1200.
- 18 J. D. SWALEN, J. Chem. Phys., 23 (1955) 1739.
- 19 L. O. BROCKWAY, J. Chem. Phys., 41 (1937) 185; J. HINE, J. Am. Chem. Soc., 85 (1963) 3239.
- 20 R. J. GILLESPIE, J. Chem. Educ., 40 (1963) 295.
- 21 R. HOFFMAN, J. Chem. Phys., 39 (1963) 1397.
- 22 E. CLEMENTI AND D. L. RAIMONDI, J. Chem. Phys., 38 (1963) 2686.
- 23 H. BASCH, A. VISTE AND H. B. GRAY, Theoret. Chim. Acta (Berlin), 3 (1965) 458.
- J. Mol. Structure, 8 (1971) 395-400